



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE  
(Attorney Docket No. SEM4492P0020US; Corporate Docket No. P98-0025)

In the Patent Application of:

Linlin Chen

Serial No.: 09/045,245

Filed: March 20, 1998

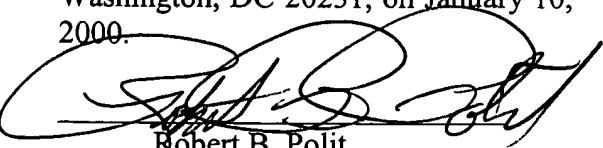
For: APPARATUS AND  
METHOD FOR  
ELECTROLYTICALLY  
DEPOSITING COPPER ON A  
SEMICONDUCTOR  
WORKPIECE

Examiner: W. Nicolas

Art Unit: 1741

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being sent via First Class Mail - Postage Pre-Paid to: Assistant Commissioner for Patents, Washington, DC 20231, on January 10, 2000.

  
Robert B. Polit  
Reg. No. 33,993

**REQUEST FOR APPROVAL OF DRAWING CHANGES**

Assistant Commissioner for Patents  
Washington, D.C. 20231

Sir:

In response to the Office Action dated July 9, 1999, Applicant hereby requests that the changes to Figures 2B-2D, as highlighted in the attached drawings, be approved for entry. Such changes bring the Figures into conformance with the corresponding description found on page 11 of the application and do not add new matter.

Further, Applicant requests entry of Figure 7 in the present application. The contents of Figure 7 merely tracks the language describing Figure 7 at p. of the application and does not add new matter.